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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/212,726
Filing Date December 15, 1998
Inventor..... Klaus F. Schuegraf
Assignee..... Micron Technology, Inc.
Group Art Unit..... 2813
Examiner Kielin, Erik J.
Attorney's Docket No. MI22-1098
Title: Semiconductor Processing Methods of Chemical Vapor Depositing SiO₂ on a
Substrate

RESPONSE TO APRIL 28, 2003 OFFICE ACTION

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From: Jennifer J. Taylor, Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)
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AMENDMENTS

Introductory Comments

In reply to the office action dated April 28, 2003, applicant amends and remarks as follows.